Fluorination of $C_6F_5MX_3$ compounds (M = Si, Ge; X = F, Cl, Br, Alk) with xenon difluoride and XeF^+Y^- salts^{*}

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(Received December 13, 1991; accepted May 6, 1992)

Abstract

Compounds of the formula $C_6F_5MX_3$ (M= Si, Ge; X = Cl, Br) react with XeF₂, exchanging chlorine (bromine) atoms for fluorine. Interaction of $C_6F_5MX_3$ (X=F, Alk) with XeF₂ in the presence of $BF_3 \cdot OEt_2$ or with $X \cdot F^+ N \cdot bF_6^-$ proceeds by the addition of two fluorine atoms to the pentafluorophenyl ring.

Introduction

Polyfluoroaromatic compounds containing Cl, Br, H, OAlk, $NO₂$ or $CF₃$ as substituents in addition to fluorine react with xenon difluoride in the presence of fluoride ion acceptors (acidic conditions) to form 1,4-cyclohexadiene or dihydronaphthalene derivatives [1]. The effect of XeF_2 on polyfluoroaromatics containing a heteroatom in a side-chain has, however, been virtually ignored. Bardin *et al.* [2 1 have shown that pentafluorophenylcontaining silanes $(C_6F_5)_n\text{SiMe}_{4-n}$ $(n = 1, 2, 4)$ react with XeF₂ and CsF in MeCN (basic conditions) (20-40 \degree C) to give pentafluorobenzene and decatluorobiphenyl. The reaction of XeF₂ with $B(C_6F_5)_3$ in CH₂Cl₂ below -40 °C (acidic conditions) allows the isolation of $C_6F_5Xe^+$ salts in high yield [3-5]. In MeCN (basic conditions), $X \nE_2$ reacts with $B(C_6F_5)_3$ at higher temperatures to yield the $[MeCN \cdot XeC_6F_5]^+$ cation in addition to several byproducts [6]. Following the discovery of the pentafluorophenylxenon cation, extensive research of the properties and reactivity of this unusual electrophile has commenced [7-9]. This has made an investigation of the reactions of $XeF₂$ with polyfluorinated aryl organoelement compounds necessary, a situation where xenon difluoride could behave as an oxidant as well as an electrophile.

It should be noted in this connection that the reactivity of xenon difluoride is very similar to that of halogen fluorides. In particular, in the presence of Lewis acids, ClF₃, BrF₃, BrF₅ [10] and IF₅ [11] fluorinate polyfluoroaromatic

^{*}Dedicated to Prof. Dr P. Sartori on the occasion of his 60th birthday.

compounds in just the same way as $X \nEpsilon_2$. However, pentafluorophenylcontaining silanes $(C_6F_5)_n$ SiMe_{4-n} or C_6F_5 SiF₃ react with BrF₃, BrF₅ and IF₅ preferentially in basic medium to form the organic derivatives of polyvalent halogens $C_6F_5BrF_n$ ($n=2, 4$) and $C_6F_5IF_4$ [12-17] in good yield. The inertness of XeF₂ towards $(C_6F_5)_n\text{SiMe}_{4-n}$ $(n=1, 2)$ under these conditions [2] led us to increase the reactivity of $X \n\in \mathbb{F}_2$ by introducing fluoride ion acceptors, and to investigate the interaction of XeF_2 , XeF_2-BF_3 . OEt₂ and XeF^+ Y⁻ with $C_6F_5SiX_3$ and $C_6F_5GeX_3$ (X = halogen).

Results and discussion

Trimethylsilylpentafluorobenzene (l), dimethylbis(pentafluorophenyl) silane (2) and triethylgermylpentafluorobenzene (3) do not react with $X \nE_2$ in CH₂Cl₂ at 20-40 °C. In the presence of $BF_3 \cdot OEt_2$ as a fluoride ion acceptor, the reactivity of $X \n\t\epsilon F_2$ increases dramatically due to xenon-fluorine bond polarization, so that at room temperature compounds 1, 3 and 4 are quickly converted to the 1-substituted heptafluoro-1,4-cyclohexadienes (5-7).

 $C_6F_5MR_3 + XeF_2 \xrightarrow{BF_3 \cdot OEt_2} \qquad \qquad \boxed{F} \qquad \boxed{MR_3}$ $(1, 3, 4)$ 5-7 **MR₃**=SiMe₃ (1, 5), GeEt₃ (3, 6), SiMe₂F (4, 7)

The reaction of excess XeF_2 with $(C_6F_5)_2SiMe_2$ and $BF_3 \cdot OEt_2$ leads mainly to bis(heptafluoro-1,4-cyclohexadien-1-yl)dimethyl-silane (8) , but the product of the fluorination of one pentafluorophenyl ring (9) has also been isolated.

As shown by GLC and "F NMR data, the fluorination of compounds 1, 2 and 4 by xenon difluoride and $BF_a \cdot OEt_a$ in CH_aCl_a leads to the formation of traces of hexafluorobenzene (not more than 1 or 2%).

For compounds containing silicon- and germanium-bonded alkyl groups substituted by chlorine and bromine, one could expect not only aromatic ring fluorination but also halogen exchange for fluorine. Indeed, tribromogermylpentafluorobenzene (10) readily reacts with XeF₂ at 25-30 °C in CH₂Cl₂ in the absence of a catalyst to form trifluorogermylpentafluorobenzene (11) , xenon and bromine. But with trichlorogermylpentafluorobenzene (12), chlorine exchange for fluorine is much slower. Along with the starting germane 12 and the final germane 11 , the reaction mixture contains a considerable amount of intermediate products $C_6F_5GeFCI_2$ and $C_6F_5GeF_2Cl$. Heating compound 12 and XeF_2 at 66 °C gives a 1:2.75 mixture of $C_6F_5GeF_2Cl$ and $C_6F_5GeF_3$, and at temperatures above 100 °C, $C_6F_5GeF_3$ and the products of fluorination of the aromatic ring are formed. Trichlorosilylpentafluorobenzene (13) is less reactive than trichlorogermylpentafluorobenzene. Refluxing the mixture with XeF_2 in CH_2Cl_2 leads to formation of only traces of $C_6F_5SiFCl_2$. But chlorodimethylsilylpentafluorobenzene (14) is readily transformed into fluorodimethylsilylpentafluorobenzene (4).

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\frac{mx_3 - GeBr_3}{(10)} \cdot C_6F_5GeF_3
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$$
(10) \qquad (11)
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$$
C_6F_5MX_3 + XeF_2
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$$
\frac{mx_3 - GeCI_3}{(12)} \cdot C_6F_5GeFCI_2 + C_6F_5GeF_2Cl + C_6F_5GeF_3
$$
\n
$$
\frac{mx_3 - SiCl_3}{(12)} \cdot C_6F_5SiFCI_2 \text{ (traces)}
$$
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$$
(13)
$$
\n
$$
C_6F_5SiMe_2Cl + XeF_2 \xrightarrow{CH_2Cl_2} C_6F_5SiMe_2F + Xe + Cl_2
$$
\n
$$
(14) \qquad (4)
$$

Addition of BF_3 OEt₂ to a mixture of $C_6F_5GeCl_3$ or $C_6F_5SiCl_3$ with XeF_2 in CH_2Cl_2 (40 °C) does not essentially change the product composition. No oxidation of the aromatic ring takes place, either. It should be mentioned that trifluorosilyl- and trifluorogermyl-pentafluorobenzenes also do not react with $XeF_2-BF_3 \cdot OEt_2$ at 40 °C in CH_2Cl_2 .

To increase the reactivity of xenon difluoride, we used niobium pentafluoride as a stronger Lewis acid. NbF_5 reacts with xenon difluoride giving the salts XeF^+ NbF₆⁻ or $Xe_2F_3^+$ NbF₆⁻ [18]. Since CH_2Cl_2 reacts vigorously with XeF^+ NbF₆⁻, we used SO₂FCl as the solvent. It should be noted that niobium pentafluoride is virtually unreactive with $C_6F_5SiCl_3$ in SO_2FCI (20-30) "C, 20 min), whereas on heating above 120-130 "C in the absence of a solvent $C_6F_5SiCl_3$ reacts with NbF₅ and $C_6F_5SiF_3$ is distilled off in good yield. Trichlorogermylpentafluorobenzene distils unchanged from the Nb F_5 solution.

Addition of XeF₂ to the SO₂FCl solution of C₆F₅SiCl₃ and NbF₅ at -30 to -40 °C brings about immediate liberation of a gas. After the addition of more than a half of the reagent, the liberation of gas ceases. Heating the solution to -10 °C again leads to gas liberation. The mixture was heated to 8-10 "C and the volatile products were collected. Their subsequent distillation gave a colourless liquid whose main components were l-trifluorosilylheptafluoro-1,4-cyclohexadiene (16) and, possibly, an isomeric mixture of 1-trifluorosilylchlorooctafluorocyclohexene (16) (15:16 = 1:2) (¹⁹F NMR data). The product 16 could not be isolated by distillation, but its presence was indicated by the signals of three AB systems $[J_{AB} = \sim 250-290$ Hz] in the 27-72 ppm range and an SiF_3 group signal of corresponding intensity at 29 ppm. One can suggest that compound 16 is obtained as a result of the chlorofluorination of a heptafluoro-1,4-cyclohexadien-l-y1 fragment of an organylsilane by the electrophilic chlorinating intermediate formed as a result of the transformation of $-SiCl_3$ to $-SiF_3$ by XeF^+ NbF₆⁻.

$$
C_{6}F_{5}SiCl_{3} + XeF + NbF_{6} \xrightarrow{SO_{2}FCI} \begin{pmatrix} F \\ F \end{pmatrix} SiF_{3} \xrightarrow{CI} SiF_{3} \begin{pmatrix} F \\ G \end{pmatrix} SiF_{3}
$$
\n(18)

Interaction of $C_6F_5SiF_3$ with $XeF^+NbF_6^-$ in SO₂FCl occurs at -40 °C to -30 °C with gas liberation. The main reaction product is cyclohexadiene (15). In addition to the signals of this compound, the 19 F NMR spectrum of the reaction product contained the signals of other unsaturated compounds which are possibly isomers of the diene 16. The elemental analysis data for the set of fluorination products corresponded to the formula $C_6F_{10}Si$.

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C_6F_5SIF_3 + XeF + NbF_6
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C_6F_5SIF_3 + XeF + NbF_6
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30 - +80°C
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Treatment of this mixture with niobium pentafluoride in SO_2FCI (20 °C) led to a decreased intensity of the signals of diene 16 and an increased intensity for the signals at 69.4, 51.5, 36.9, 16.4 and 12.6 ppm (1:2:2:1:1) which may be assigned to the fluorine atoms of l-trifluorosilyl-heptafluoro-1,3 cyclohexadiene.* It is important that the elemental composition (C, F) does not change during this process. Treatment of $C_6F_5SIF_3$ with excess XeF^+ NbF₆⁻ from -30 °C to 80 °C led to trifluorosily honafluorocyclohexene (17).

The reaction of $C_6F_6GeF_3$ with XeF⁺ NbF₆⁻ at -40 °C to -30 °C proceeds in a similar manner. The products are l-trifluorogermyl-heptafluoro-1,4-cyclohexadiene (18) and polyfluorinated unsaturated compounds. The 19 F NMR signals of the latter have the same fine structure as those of the respective products of the fluorination of $C_6F_5S\ddot{F}_3$ but differ in chemical shift values. Treatment of $C_6F_5GeF_3$ with xenon difluoride at 20–40 °C in the presence of SbF_3 (catalyst) gives a mixture of cyclohexadiene (18) and l-trifluorogermylnonafluorocyclohexene (19) (2: 1). Further fluorination of this mixture by xenon difluoride leads to olefin 19.

The new compounds 4-9, 17 and 19 have been characterized by elemental analysis, IR, 'H and "F NMR data. The chemical shifts and coupling constants of the fluorine signals in the 19 F NMR spectra of compounds 5–18 unambiguously indicate the structures of 1 -substituted-heptafluoro-1,4-cyclohexadienes $[19-23]$. The IR spectra of compounds $5-9$ exhibit vibration bands at 1772-1774 cm⁻¹ (FC=CF) and at 1680-1684 cm⁻¹ (FC=CMX). The 19 F NMR spectra of compounds 17 and 19 are typical for 1-substitutednonafluorocyclohexenes [191.

^{*}Reliable structural identification of substituted heptafluoro-1,3-cyclohexadienes by their 19 F NMR spectra in a mixture is impossible because of the unavailability of spectrum-structure correlations for these compounds in the literature.

Experimental

'H and "F NMR spectra were recorded on Bruker WP 200 SY and AC 200 instruments $(^{1}H$ at 200 MHz frequency, internal standard TMS; ^{19}F at 188.3 MHz frequency, internal standard C_6F_6 , $\delta(CFCl_3) = +162.9$ ppm). IR spectra were recorded on a Specord M 80 instrument using a thin layer. GLC analysis was carried out on an LKhM 72 instrument (15% SKTFI' 803 on Chromosorb W). Dichloromethane was dried with P_4O_{10} and distilled. SO_2 FCl was distilled twice over SbF_5 . Niobium pentafluoride was distilled in an apparatus constructed of quartz and Kel-F. XeF^+ Nb F_6^- was prepared according to literature methods [18]. All experiments were performed in a dry argon atmosphere. Tables l-3 give the NMR, IR and analytical data of the new compounds.

Fluorination of C_6F_5S *iMe₃* (1)

Compound **1** (13.9 g, 58 mmol), 15 ml CH_2Cl_2 and a few drops of $BF_3 \cdot OEt_2$ were placed in a quartz flask. Then XeF_2 (11.0 g, 64.7 mmol) was added in portions with stirring and cooling (cold water). The mixture was stirred for 30 min, 10 ml water added, the organic layer separated, the mixture dried with $CaCl₂$ and the solvent distilled off. According to ¹⁹F NMR data, the reaction mixture contained traces of hexafluorobenzene and ltrimethylsilylheptafluoro-1,4-cyclohexadiene (5) (nc). The latter was isolated by distillation. Yield 11.9 g (74%).

Fluorination of $(C_6F_5)_2$ *SiMe₂ (2)*

Compound 2 (5.7 g, 14.5 mmol) was reacted with 6.6 g (38.8 mmol) of $X \n\t\epsilon F_2$, 15 ml CH₂Cl₂ and a few drops of BF₃ OEt₂. After reaction, the mixture (5.5 g) contained traces of C_6F_6 , 1-dimethylpentafluorophenylsilylheptafluoro-1,4-cyclohexadiene (9) (nc) and bis(heptafluoro-1,4-cyclohexadien-1-yl)dimethylsilane (8) (nc) (NMR data) yields (11% and 55%, respectively, by GLC). Compounds 8 and 9 were isolated by preparative GLC methods.

Fluorination of C_6F_5GeEt *, (3)*

Compound 3 (13.1 g, 40.1 mmol), $X \nE_2$ (9.1 g, 53.5 mmol), 15 ml CH_2Cl_2 and a few drops of $BF_3 \cdot OEt_2$ were reacted to give, after removal of solvent, a mixture containing C_6F_6 (traces) and 1-triethylgermylheptafluoro-1,4-cyclohexadiene (6) (nc) (NMR data). Distillation afforded 10.6 g (72%) of compound 6.

Fluorination of C_6F_5S *iMe₂F (4)*

Compound 4 (3.40 g, 13.9 mmol), 6 ml CH_2Cl_2 , 2.50 g (14.7 mmol) of XeF₂ and a few drops of $BF_B \cdot OEt_2$ were refluxed for 1 h and then distilled to yield 0.2 g of the starting silane 4 and 2.4 g $(61%)$ of 1-fluorodimethylsilylheptafluoro-1,4-cyclohexadiene (7) (nc).

NMR spectral data

"At 45 "C.

^bNo first order analysis possible.

 $c_{n.d.}$ = not determined.

Fluorination of $C_6F_5SiMe_2Cl$ *(14)*

In a quartz flask equipped with magnetic stirrer (with an anchor coating of Teflon) and a reflw condenser linked to a bubble counter, were placed $XeF₂$ (1.7 g, 10 mmol) and 10 ml CH₂Cl₂. Then 5.0 g (19 mmol) of compound

TABLE 3

Analytical data

14 was added with a syringe while the mixture was cooled with cold water. The mixture was refluxed for 15 min, the solvent distilled off and the residue distilled to give 4.2 g (89%) of fluorodimethylsilylpentafluorobenzene (4 (nc).

Fluorination of C,F, GeBr, (10)

Compound 10 (5.3 g, 11 mmol) and 6 ml $CH₂Cl₂$ were placed in a Kel-F reactor and $X \nE_2$ (2.8 g, 38 mmol) added in small portions with stirring. The dark red solution formed was stirred for 15 min at 25-30 "C. Distillation at reduced pressure gave 3.0 g (91%) of trifluorogermylpentafluorobenzene (11) $[24]$.

Fluorination of $C_6F_5GeCl_3$ *(12)*

Method A

Compound 12 (6.8 g, 19.7 mmol), XeF_2 (5.1 g, 30 mmol) and 10 ml CH_2Cl_2 were treated as above to give 5.7 g of a 2:3.8:3:1 mixture of compounds $C_6F_5GeCl_3$, $C_6F_5GeCl_2F$, $C_6F_5GeClF_2$ and $C_6F_5GeF_3$ (¹⁹F NMR data). The earlier unreported compounds $C_6F_5GeCl_2F$ and $C_6F_5GeCl_2F_2$ were assigned to the following ¹⁹F NMR signals (cf. with the spectra of $C_6F_6GeF_3$ and $C_6F_5GeCl_3$) (in CDCl₃):

 $C_6F_5GeF_3$: 38.3 (2 $F^{2,6}$); 22.6 (1 F^4); 5.91 (2 $F^{3,5}$); 11.5 (GeF_3) ppm. C₆F₆GeClF₂: 37.3 (2F^{2,6}); 21.4 (1F⁴); 5.63 (2F^{3,5}); 27.0 (GeClF₂) ppm. $C_6F_5GeCl_2F: 36.3 (2F^{2,6}); 20.0 (1F^4); 5.04 (2F^{3,5}); 36.3 (GeCl_2F)$ ppm. $C_6F_5GeCl_3$: 35.7 (2 $F^{2,6}$); 18.8 (1 F^4); 4.47 (2 $F^{3,5}$) ppm.

Method B

To a solution of compound 12 (3.3 g, 9.5 mmol) in 3 ml CH_2Cl_2 , xenon difluoride $(3.3 g, 19.4 mmol)$ was added in portions and the mixture heated for 2 h at 66 °C (bath). Distillation gave 2.0 g of a colourless fuming liquid containing $C_6F_5GeClF_2$ and $C_6F_5GeF_3$ (1:2.75) (¹⁹F NMR data).

Method C

Compound 12 (3.0 g, 8.6 mmol) was placed in a quartz flask and then $XeF₂$ (2.9 g, 17 mmol) added with stirring. The temperature was raised to 160 "C (bath) over 30 min and a colourless liquid (which fumed in air) was distilled off (1.8 g). The liquid contained $C_6F_5GeF_3$ (11), $1-GeF_3=1,4-C_6F_7$ (18), GeF₃-1,3-C₆F₇ and 1-GeF₃C₆F₉ (19) (7:3.5:1.7:1) (¹⁹F NMR data).

Method D

Compound 12 (4.3 g, 12 mmol) and NbF₅ (3.0 g, 16 mmol) were placed in a quartz flask. The mixture was heated to $220-230$ °C (bath) allowing the volatile products to distil off. The cooled distillate was filtered from NbF_5 and redistilled. This procedure gave 3.8 g (88%) of the starting germane 12 (b.p., 203-207 "C [25]).

Fluorination of $C_6F_5SiCl_3(13)$

Method A

Compound 13 (7.0 g, 23 mmol), 10 ml CH_2Cl_2 and XeF_2 (5.9 g, 34 mmol) were refluxed for 15 min to afford 5.3 g of silane 13 containing traces of $C_6F_5SiFCl_2$ which was assigned ¹⁹F NMR signals at 36 ($2F^{2,6}$), 18.2 $(1F⁴)$, 3.5 $(2F^{3,5})$ and 32 (SiFCl₂) ppm.*

Method B

Compound 13 (4.0 g, 13.2 mmol) and NbF_5 (2.5 g, 13.3 mmol) were placed in a flask. The mixture was heated to 130-140 "C allowing the volatile products to distil off. The mixture was then heated to give 2.6 g (78%) of $C_6F_5SiF_3$ [24].

Method C

The quartz flask equipped with a thermometer, magnetic stirrer and bubbler was cooled in an argon atmosphere to -40 °C and NbF₅ (1.2 g, 6) mmol), SO_2FCl (13 ml) and compound 13 (3.0 g, 10 mmol) were placed in it. Then XeF_2 (5.1 g, 30 mmol) was added in small portions with stirring. The mixture was allowed to stand for 20 min at 8-10 $^{\circ}$ C, the volatile products recondensed *in vacuo* (18 Torr) into a cooled trap $(-70 \degree C)$ and then distilled. This gave 1.6 g of a colourless liquid containing compounds 16 and 16 $(-1:2)$ (¹⁹F NMR data).

Fluorination of $C_6F_5SiF_3$

Method A

A Teflon reactor equipped with a magnetic stirrer and a bubbler was cooled in an argon atmosphere to -40 °C, and 1.26 g (5 mmol) of $C_6F_5SiF_3$ and 5 ml of SO_2 FCl were placed in it. Then XeF^+ NbF₆ (2.40 g, 6.7 mmol) was added in small portions with stirring and the mixture heated for 1.5 h to lo-15 "C. The volatile products were recondensed *in vacua* (10 Torr) into a trap $(-70 \degree C)$. This gave 1.0 g of a liquid containing 2.4 mmol of compound 16 and presumably trifluorosilylheptafluoro-1,3-cyclohexadienes $(^{19}F$ NMR data). Analysis: Found: C, 25.2; F, 65.0%. C₆F₁₀Si requires: C, 24.8; F, 65.5%.

Method B

Addition of 1.20 g (7.0 mmol) of XeF_2 to 1.40 g (5.56 mmol) of $C_6F_5SiF_3$, 5 ml SO₂ClF and 0.25 g (1.4 mmol) of NbF₅ at -30 °C afforded 1.4 g of a product containing compound 15 (3.1 mmol) and $C_6F_7SiF_3$ (1 mmol) (¹⁹F) NMR data).

Method C

Heating $C_6F_5SiF_3$ (2.0 g, 7.9 mmol), XeF_2 (6.3 g, 17.6 mmol) and 5 ml SO₂FCl from -30 °C to 80 °C (bath) gave 1.7 g (65%) of 1-trifluorosilylnonafluorocyclohexene (17) (nc).

Reaction of NbF₅ with perfluorotrifluorosilylcyclohexadienes

A mixture consisting of perfhrorotrifluorosilylcyclohexadienes obtained in the previous experiment (B) (0.5 g, 1.7 mmol), 0.5 g (2.6 mmol) of NbF_5

^{*}C₆F₅SiFCl₂ has been described (b.p., IR spectrum and elemental analysis) but no ¹⁹F NMR spectrum was given [26].

and 0.5 ml SO₂FCl was placed in a glass tube. The mixture was shaken for 8 h at room temperature, SO₂FCl distilled off and the residue recondensed *in vacua* when 0.5 g of a 1:2 mixture of the starting compounds was obtained (¹⁹F NMR data). Analysis: Found: C, 24.5; F, 65.0%. $C_6F_{10}Si$ requires: C, 24.8; F, 65.5%.

Fluorination of $C_6F_5GeF_3$ (11)

Method A

The reaction was performed in a similar fashion to the fluorination of $C_6F_5SiF_3$ (method A). Compound 11 (0.50 g, 1.68 mmol) was reacted with XeF^+ NbF₆⁻ (0.72 g, 2.0 mmol) and 5 ml SO₂FCl to produce 0.4 g of a product containing compounds 11, 18 and presumably trifluorogermylheptafluoro-1,3-cyclohexadiene (3:7:1) (19 F NMR data).

Method B

To a stirred mixture of compound 11 (6.0 g, 20 mmol) and $XeF₂$ (6.46) g, 38 mmol), SbF_3 (0.05 g, 0.3 mmol) was added at 10 °C. An exothermic reaction commenced immediately with vigorous liberation of gas. After $10-15$ min, the volatile products were recondensed into a trap $(-70 \degree C)$. This gave 4.7 g of a mixture of 1-trifluorogermylheptafluoro-1,4-cyclohexadiene (18) (nc) and 1-trifluorogermylnonafluorocyclohexene (19) (nc) (2:1) $(^{19}F$ NMR data).

Fluorination of compound 18

A mixture of compounds 18 and 19 (4.3 g) obtained in the previous experiment and 50 mg of SbF_3 were placed in a quartz flask provided with a magnetic stirrer and a reflux condenser with a bubbler. Then XeF_0 (2.0) g) was added in small portions. After the reaction was complete (3-5 min), the reaction mixture was cooled, the liquid separated from the solid residue and distilled in a quartz apparatus under a dry argon atmosphere. This gave a colourless liquid which fumed strongly in air. The yield of l-trifluorogermylnona-fluorocyclohexene (19) (nc) was 3.0 g (65%).

Acknowledgements

We gratefully acknowledge Deutsche Forschungsgemeinschaft and Fonds der Chemischen Industrie for their financial support.

References

- 1 V. V. Bardin and Yu. L. Yagupolskii, in L. German and S. Zemskov (eds.), New Fluorinating *Agents for Organic Synthesis,* Springer-Verlag, Berlin, 1989, p. 1.
- 2 V. V. Bardin, I. V. Stennikova, G. G. Furin, T. V. Leshina and G. G. Yakobson, Zh. Obshch. *Khim., 58* (1988) *2580 [Chem. Abs., 111 (1989) 1342541.*
- *3* W. Breuer, H. J. kohn and St. Jakobs, *12th Int. Symp. Fluorine Chem.,* Santa Cruz, CA, 1988, Abstract P213.
- 4 H. J. Frohn and St. Jakobs, J. Chem. Soc., Chem. Commun., (1989) 625.
- 5 H. J. Frohn, St. Jakobs and G. Henkel, *Angew. Chem., Int. Ed. Engl., 28* (1989) 1506.
- 6 D. Naumann and W. Tyrra, J. Chem. Soc., Chem. Commun., (1989) 47.
- 7 H. J. Frohn and St. Jakobs, J. *Fluorine Chem.,* 45 (1989) 11.
- 8 H. J. Frohn, St. Jakobs and Ch. Rossbach, J. *Fluroine Chem.,* 54 (1991) 8.
- 9 H. J. Frohn, St. Jakobs and Ch. Rossbach, *Eur. J. Solid State Iwg. Chem., 29* (1992) 729.
- 10 L. S. Boguslavskaya and N. N. Chuvatkin, in L. German and S. Zemskov (eds.), New *Fluorinating Agents for Organic Synthesis, Springer-Verlag, Berlin, 1989, p. 140.*
- 11 H. J. Frohn, S. Gorg, Ch. Klockhaus and R. Nielinger, J. *Fluorine Chem., 54* (1991) 324.
- 12 H. J. Frohn and J. Helber, J. *Fluorine Chem., 16* (1980) *568.*
- *13* H. J. Frohn, *Chem.-Ztg., 108* (1984) 146.
- 14 H. J. Frohn and M. Giesen, J. *Fluorine Chem., 24* (1984) 9.
- 15 W. Breuer and H. J. Frohn, J. *Fluorine Chem.* 34 (1987) 443.
- 16 W. Breuer and H. J. Frohn, *J. Fluorine Chem., 47* (1990) 301.
- 17 W. Breuer and H. J. Frohn, Z. *Awg. Allg. Chem.,* 610 (1992) 1.
- 18 J. H. Holloway and J. G. Knowles, *J. Chem. Sot. A,* (1969) 756.
- 19 S. F. Campbell, A. G. Hudson, E. F. Mooney, A. E. Pedler, R. Stephens and K. N. Wood, *Spectrochim. Acta, 23A* (1967) 2119.
- 20 J. Riera and R. Stephens, *Tetrahedron, 22* (1966) 2555.
- 21 A. A. Shtark and V. D. Shteingarts, *Izv. Sib. Otd. Akad. Nauk SSSR, Ser.* Khim. Nauk, (1976) 123 [Chem. Abs., 85 (1976) 176 911].
- 22 A. A. Shtark and V. D. Shteingarts, *Zh. Org. Khim., 12* (1976) 1499 [Chem. Abs., 85 *(1976) 176 5051.*
- *23* W. P. Dailey, R. A. Correa, E. Harrison and D. M. Lemal, *J. Org. Chem.,* 54 (1989) 5511.
- 24 M. Weidenbruch and N. Wessal, *Chem. Ber., 105* (1972) 173.
- 25 V. V. Bardin, L. N. Aparina and G. G. Fur-in, Zh. *Obshch. Khim.,* 61 (1991) 1414.
- 26 J. M. Birchall, W. M. Daniewski, R. N. Haszeldine and L. S. Holden, *J. Chem. Sot.,* (1965) 6702.